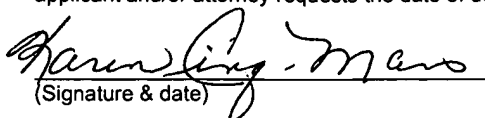


I hereby certify that this correspondence is being deposited with the United States Postal Service via Express Mail Certificate No.: ER046066445US1 addressed to : Commissioner of Patents and Trademarks, Alexandria, VA 22313, on March 1, 2004. The applicant and/or attorney requests the date of deposit as the filing date. Depositor: Karen Cinq-Mars

 3/1/04
(Signature & date)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of _____: March 1, 2004
Dureseti Chidambarao, et al.: Group Art Unit:
Serial No. to be assigned _____: Examiner: to be assigned
Filed: 3/1/04 _____: International Business Machines Corporation
2070 Route 52
Hopewell Junction, NY 12533

TITLE: METHOD AND MANUFACTURE OF FINFET DEVICES WITH T-SHAPED FINS AND
DEVICES MANUFACTURED THEREBY

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

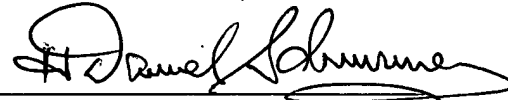
Sir:

Pursuant to the duty of disclosure set forth in 37 C.F.R. 1.56, and further pursuant to the provisions of 37 C.F.R. 1.97 and 1.98, applicants hereby respectfully submit copies of the non-US patents and publications as listed on Form PTO-1449, attached hereto.

In citing these documents, no representation is made nor intended as to the pertinency or non-pertinency of the art, that better art than that listed is not available, or that other art is not applicable.

No fee is believed to be due for this submission. If any fees are required, however, the Commissioner is hereby authorized to charge such fees to Deposit Account No. 09-0458.

Respectfully submitted,
Dureseti Chidambarao, et al.

By 

H. Daniel Schnurmann
Registration No. 35,791
Telephone No. 845-894-2481

PAGE 1 OF 2

FORM PTO-1449 (Modified) LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	Attorney Docket Number: FIS920030388US1	Serial Number
	APPLICANT: Omer Dokumaci et al.	
	Filing Date:	Group:

Examiner Initials		Document Number	Issued Date	Name	Class	Subclass	FILING DATE (IF APPRO.)
	AA	6,252,284	26 Jun. 2001	Muller et al.	274	412	
	AB	6,352,872	5 Mar. 2002	Kim et al.	438	24	
	AC	6,391,695	21 May 2002	Yu	438	166	
	AD	6,413,802	2 Jul. 2002	Hu et al.	438	151	
	AE	6,429,061	6 Aug. 2002	Rim	438	198	
	AF	6,433,609	13 Aug. 2002.	Voldman	327	313	
	AG	6,583,015	24 Jun. 2003	Fitzgerald	438	287	
	AH	6,583,469	24 Jun. 2003	Fried et al.	257	329	
	AI	6,603,156	5 Aug. 2003	Rim	257	190	
	AJ	6,610,576	26 Aug. 2003	Nowak	438	301	
	AK	6,611,029	26 Aug. 2003	Ahmed et al.	257	365	
	AL	6,635,909	21 Oct. 2003	Clark et al.	257	192	
	AM	6,642,090	4 Nov. 2003	Fried et al.	438	164	
	AO	6,642,536	4 Nov. 2003	Xiang et al.	257	19	
	AP	6,657,252	2 Dec. 2003	Fried et al.	257	316	
	AQ	6,657,259	2 Dec. 2003	Fried et al.	257	350	
	AR	6,662,350	9 Dec. 2003	Fried et al.	716	11	
	AS	6,664,582	16 Dec. 2003	Fried et al.	257	308	

EXAMINER**DATE CONSIDERED**

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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FORM PTO-1449 (Modified) LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	Attorney Docket Number: FIS920030388US1	Serial Number
	APPLICANT: Omer Dokumaci et al.	
	Filing Date:	Group:

		Published Application No.	Publication Date	Name	Class	Subclass	
	AT	2003 0227036	11 Dec. 2003	Sugiyama et al.	257	288	
	AU	2004 0007715	15 Jan. 2004	Webb et al.	257	192	

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AX	Wong et al. "Self-Aligned (Top and Bottom) Double-Gate MOSFET with a 25nm Thick Silicon Channel, IEDM pp 97-427 to 430, pp. 16.6.1-16.6.4", 1997 IEEE
	AW	Leobandung et al. "Wire-channel and Wrap-Around-Gate Metal-Oxide-Semiconductor Field-Effect Transistors with a Significant Reduction of Short Channel Effects", J. Vac. Sci Technol. B 15 (6), Nov/Dec 1997 American Vacuum Society , pp. 2791-2794
	AX	Huang et al. "Sub 50-nm FinFET: PMOS" 1999 IEEE, IEDM 99-67 to 70, pp 3.4.1 to 3.4.4, 1999 IEEE
	AY	Huang et al. "Sub 50-nm FinFET" IEEE Transactions on Electron Devices, Vol. 48, No. 5 May 2001, pp 880-886, 2001 IEEE
	AZ	Tezuka et al. "High-performance Strained Si-on-Insulator MOSFETs by Novel Fabrication Processes Utilizing Ge-Condensation Technique", 2002 Symposium On VLSI Technology Digest of Technical Papers, 10.3, pp. 96-97, 2002 IEEE

EXAMINER	DATE CONSIDERED
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